

Search Notes

Application/Control No.

10/763,224

Examiner

Richale L. Haney

Applicant(s)/Patent under
Reexamination

CHO, BYOUNG-WOO

Art Unit

3765

SEARCHED

| Class | Subclass | Date | Examiner |
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INTERFERENCE SEARCHED

| Class | Subclass | Date | Examiner |
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**SEARCH NOTES
(INCLUDING SEARCH STRATEGY)**

| | DATE | EXMR |
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| Search updated | 2/20/2006 | RLH |
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